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Ellipsometric investigations of Bi₂Te₃ thin films grown by electrodeposition

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IC 4

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Introduction & Objectives

Bismuth telluride (Bi2Te3) based compounds have attracted considerable interest for thermoelectric conversion at room temperature.

This material can be used as an interlayer at the back contact to improve the long term stability of the CdTe thin film solar.

A route of synthesis of Bi₂Te₃ is done by electrochemistry: polycrystalline thin films have been grown on gold substrates by electrodeposition.

The determination of the transport properties is not obvious for thermoelectric thin films. Ellipsometry may be an alternative and powerful method to characterize thin films through their optical, morphological and electronic properties

 \square

This work presents the analysis of electroplated Bi₂Te₃ layers by different ellipsometric techniques both in in situ and ex situ modes.

the optical behaviour of potentially anisotropic films of uniaxially bismuth telluride

the electronic parameters through the analysis of the dielectric function

the film growth during electroplating

Results In situ real time spectroscopic ellipsometric study

combined with Electrochemical Quartz Cristal Microbalance

Simultaneous and synchronised records of

1.Real time visible ellipsometric spectra (RTSRCE)

2.Gravimetric data (EQCM)

3.Coulometric data (Potentiostat)





Mueller-matrix of a 4 μ m-thick Bi_{2.0}Te_{3.0} sample

The spectra were realized at different angles of incidence (ϕ =65, 70 and 75°) and for multiple azimuth angles (φ , φ +45°).

N

Comments: Eight off-diagonal blocks elements $M_{ij} = 0$ polycristalline films appear optically isotropic Moreover no depolarization effect exists. In situ study Confirmation of optical isotropy from the first steps of the growth until several micrometers thick films

SEM micrographs of electroplated Bi2Te3 films



15s growth time



3600s growth time

Discussion :

the random azimuthal orientation of anisotropic crystallized is optically equivalent to an isotropic material



The following stage corresponds to a regular growth in which the optical constants vary



Growth rate : 1nm.s⁻¹

The ECD process of Bi₂Te₃ includes a

Porosity: The optical thickness and mass are consistent with an apparent density of 7.06. By comparison with the bulk density, a porosity P of 10 % may be calculated through the relation: $P=1-d_{app}/d_{theo}$.

Conclusion

10 0 3 4 Photon energy (eV) Modeled pseudo-dielectric function of a 4 μ m-thick film of Bi₂ Te₃ In the InfraRed range, the DF of the samples is

Analysis of the Dielectric Function (DF) of

the electroplated films

70

with a Drude contribution (DRD) to the DF and a With a **Drude contribution** (DRD) to the DF and a **Tauc-Lorentz contribution** (TL). In particular, the electrical resistivity and the band gap (E_g) can be extracted. The carrier concentration (N) and mobility (μ) are deduced through the value of the effective mass.



Discussion:

The analysis was successfully extended to different compositions from Bi_{1.8}Te_{3.2} up to Bi_{2.2}Te_{2.8} leading to different carrier concentrations.

- The N values show that the compounds are **heavily doped semiconductors.** No significant variation of E_g with N is observed. Some compensation seems to occur with both tailoring observence: phenomena
- •Band-gap widening by the Burnstein-Moss effect (αN

(electrons-electrons effects and electron-ion scattering)

bibliography: A. Zimmer, N. Stein, L. Johann, S. Van Gils, H. Terryn, E. Stijins, C. Boulanger, J. Electrochem. Soc. 152 (10) (2005) G772. Zimmer, N. Stein, L. Johann, R. Beck and C. Boulanger, ectrochimica Acta 52 (2007) 4760.

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Rev. Sci. Instrum., in press

This work has shown that Spectroscopic Ellipsometry can be a powerful technique to study electroplating

In situ data allowed to monitor the growth of Bi₂Te₃ films, providing their growth rate, their porosity, growth mechanisms and their optical behavior

Dielectric Functions were established, leading to the determination of the electronic parameters (Eg, resistivity, mobility) of thin films without any electrical contacts.

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Real/Dielectric 10 5

Comments:

 \geq

25

15

Function) 20

expressed as : $\varepsilon(E) = \varepsilon_{DRD}(E) + \varepsilon_{TL}(E)$



progressive covering stage in the first 30 seconds. slightly and are linked to the growth of needles

